

[10191/3964]

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : Franz LAERMER et al.
Serial No. : To Be Assigned
Filed : Herewith
For : PLASMA SYSTEM AND METHOD FOR
ANISOTROPICALLY ETCHING STRUCTURES INTO
A SUBSTRATE
Art Unit : To Be Assigned
Examiner : To Be Assigned

Mail Stop PCT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT AND
37 C.F.R. § 1.125 SUBSTITUTE SPECIFICATION STATEMENT**

SIR:

Please amend the above-identified application before examination, as set forth
below.

Amendments to the Specification begin at page 2 of this paper.

Amendments to the Claims are reflected in the listing of the claims which begins
at page 3 of this paper.

Remarks begin at page 7 of this paper.